

**METHOD AND APPARATUS FOR GENERATING VALUES FOR
SELECTED PIXELS USED IN EVALUATING SEMICONDUCTOR
WAFER BUMPS**

5

ABSTRACT

Plural light sources are provided for directing ring patterns of light toward at least one reflective bump formed on and projecting from a first wafer surface of a semiconductor wafer. The intensity of light from the light sources may be varied and may be varied independently of one another. A method and apparatus for adjusting at least one pixel value is also disclosed.